

Raman Characterisation of layered MoS₂ produced by a non-Catalytic CVD method

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Molybdenum disulphide (MoS₂) is a layered semiconductor which exhibits an indirect (1.2eV) to direct (1.8eV) bandgap transition with decreasing number of layers. This makes MoS₂ a promising candidate to override graphene in some applications due to the absence of a bandgap of the former material. A non-catalytic CVD synthesis method to fabricate MoS₂ crystals on Si/SiO₂ substrate is presented. MoS₂ is produced by sulphurisation of MoO₃ in a quartz tube furnace under N₂ flow. The main aim is to refine the growth parameters (temperature, pressure, gas flow rate) in order to produce two-dimensional MoS₂ crystals with qualities comparable to their exfoliated counterparts. Preliminary results show that triangular crystallites of about 10 to 30 microns in lateral dimensions can be produced. The synthesized crystals are comprised of areas with different number of layers (monolayer to bulk) as it is evident from the Raman and Photoluminescence (PL) maps (fig. 1c, d). The frequency difference value, $\Delta\omega$, of the A_{1g} and E_{2g} Raman modes of MoS₂ (fig. 1b) is indicative of the number of layers [1]. Additionally, the PL intensity increases dramatically by decreasing the layer number (fig. 1d), signifying the indirect to direct bandgap transition. Finally, CVD grown MoS₂ is compared with the one produced by micromechanical exfoliation.

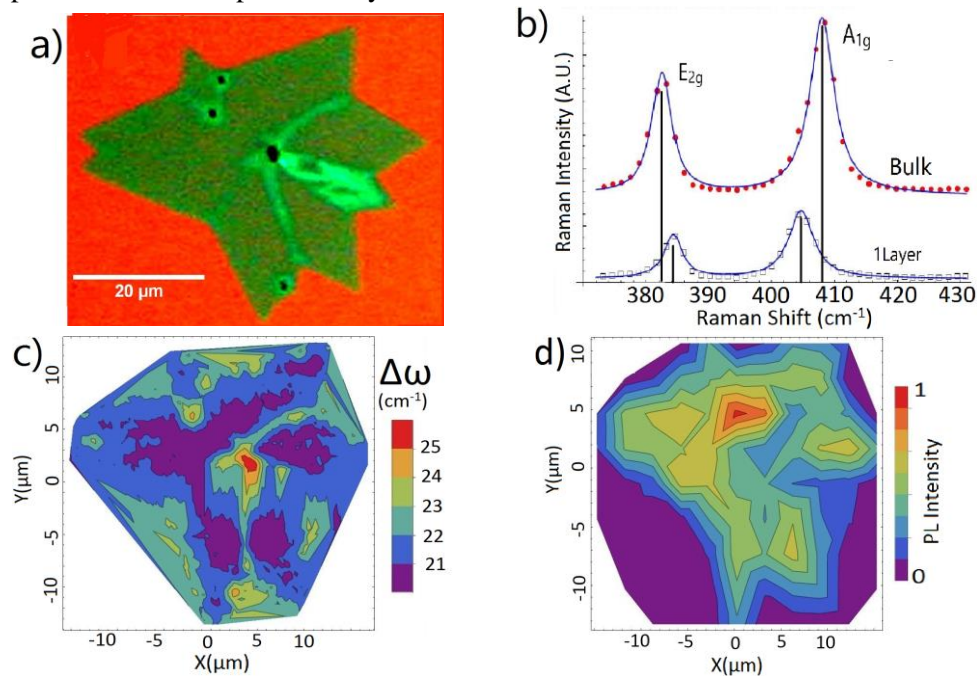


Figure 1: a) Optical image of MoS₂ crystallite, b) Raman spectra of bulk and monolayer MoS₂ where the difference $\Delta\omega$ is evident, c) $\Delta\omega$ and d) photoluminescence map of the crystallite shown in (a).

References

[1] Q. H. Wang, K. Kalantar-Zadeh, A. Kis, J. N. Coleman and M. S. Strano, *Nature Nanotechnology* **7**, 699-712 (2012)

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